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Ratio Dependence of Contact angle for Droplet Wetting on Chemically Heterogeneous Substrates

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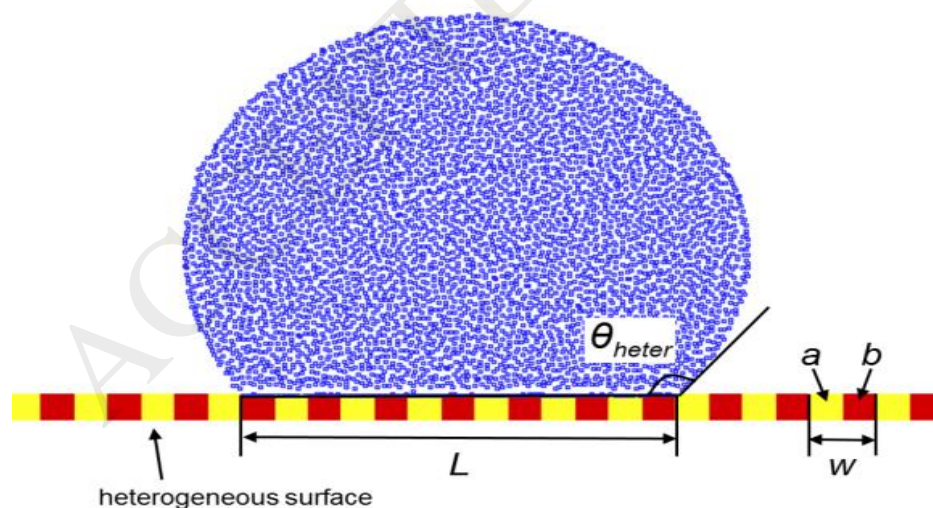
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Graphical abstract



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